

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No. 09/212,726
Filing Date December 15, 1998
Inventor Klaus Florian Schuegraf
Assignee Micron Technology, Inc.
Group Art Unit 2813
Examiner Erik J. Kielin
Attorney's Docket No. MI22-1098
Title: Semiconductor Processing Methods of Chemical Vapor Depositing SiO₂ on
a Substrate

#21
9/26/02
JTM

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

References –See Attached Form PTO-1449

The Examiner's attention is directed to the reference which is listed on the attached Form PTO-1449, a copy of the abstract of which is attached. No admission is made regarding whether the submitted reference is prior art.

Citation of the referenced art is respectfully requested.

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Respectfully submitted,

Dated: September 17, 2002

By:

Jennifer J. Taylor
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